

ABSTRACT OF THE DISCLOSURE

An optical member made of silica glass manufactured by the direct method where a material gas comprising an organosilicon compound is allowed to react in an oxidizing flame,

5

said optical member having a 2×10^{14} molecules/cm³ or less concentration of formyl radical generated by X-ray irradiation whose dose is 0.01 Mrad or more and 1 Mrad or less.